•				
ORM PTO-1390 (REV. 11-2000)	US DE	PARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTORNEY'S DOCKET NUMBER	
TRANSMITTAL LETTER TO THE UNITED STATES			1163-0345P	
DESIGNATED/ELECTED OFFICE (DO/EO/US)			U.S. APPLICATION NO. (If known, see 37 CFR 1.5)	
CONCERNING A FILING UNDER 35 U.S.C. 371			U9/889392	
INTERNATIONAL APPLI	ICATION NO.	INTERNATIONAL FILING DATE	PRIORITY DATE CLAIMED	
PCT/JP00/	07239	OCTOBER 16, 2000	NOVEMBER 16, 1999	
FITLE OF INVENTION				
ACOUSTIC WAVE APPARATUS				
APPLICANT(S) FOR DO/EO/US YOSHIDA, Kenji; WADAKA, Shusou; MISU, Koichiro; NAGATSUKA, Tsutomu; MURAI, Kouji;				
YAMAGUCHI, Masatsune; HASHIMOTO, Kenya; OHMORI, Tatsuya; IBATA, Koji				
Applicant herewith submits to the United States Designated/Elected Office (DO/EO/US) the following items and other information:				
This is a <b>FIRST</b> submission of items concerning a filing under 35 U.S.C. 371.				
This is a SECOND or SUBSEQUENT submission of items concerning a filing under 35 U.S.C. 371.				
This express request to begin national examination procedures (35 U.S.C. 371(f)) at any time rather than delay				
examination until the expiration of the applicable time limit set in 35 U.S.C. 371(b) and PCT Articles 22 and 39 (1).				
The US has been elected by the expiration of 19 months from the priority date (Article 31).				
A copy of the International Application as filed (35 U.S.C. 371(c)(2))				
is transmitted herewith (required only if not transmitted by the International Bureau). WO 01/37426				
has been transmitted by the International Bureau.				
is not required, as the application was filed in the United States Receiving Office (RO/US).				
6. An English language translation of the International Application as filed (35 U.S.C. 371(c)(2)).				
is transmitted herewith.				
has been previously submitted under 35 U.S.C. 154(d)(4)				
7. Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. 371(c)(3)).				
are transmitted herewith (required only if not transmitted by the International Bureau).				
have been transmitted by the International Bureau.				
have not been made; however, the time limit for making such amendments has NOT expired.				
have not been made and will not be made.				
8. An English language translation of the amendments to the claims under PCT Article 19 (35 U.S.C. 371(c)(3)).  9. An oath or declaration of the inventor(s) (35 U.S.C. 371(c)(4)). (Original)				
10. An English language translation of the annexes of the International Preliminary Examination Report under PCT Article 36				
(35 U.S.C. 371(c)(5)).				
Items 11. to 20. below concern document(s) or information included:				
11. An Information Disclosure Statement under 37 CFR 1.97 and 1.98./International Search Report (PCT/ISA/210) with 13 documents				
F 8	ocument for record	ing. A separate cover sheet in compliance with	h 37 CFR 3 28 and 3 31 is included	
=	inary amendment.	mg. 11 separate to ver shoot in compilation with	as y of 100.00 and 5.51 is included.	
15. A substitute specification.				
16. A change of power of attorney and/or address letter.				
7. A computer-readable form of the sequence listing in accordance with PCT Rule 13ter.2 and 35 U.S.C. 1.821-1.825.				
18. A second copy of the published international application under 35 U.S.C. 154(d)(4).				
19. A second copy of the English language translation of the international application under 35 U.S.C. 154(d)(4).				
20. Other items or information:				
1.) SEVEN (7) Sheets Formal Drawings				

AC18 Rec'd PCT/PTO 1 6 JUL 2001

PATENT 1163-0345P

# IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

YOSHIDA, Kenji et al

Conf.:

Int'l. Appl. No.:

PCT/JP00/07239

Appl. No.:

NEW

Group:

Filed:

July 16, 2001

Examiner:

For:

ACOUSTIC WAVE APPARATUS

# PRELIMINARY AMENDMENT

# BOX PATENT APPLICATION

Assistant Commissioner for Patents Washington, DC 20231

July 16, 2001

Sir:

following Preliminary Amendments and Remarks are respectfully submitted in connection with the above-identified application.

# **AMENDMENTS**

# IN THE SPECIFICATION:

Please amend the specification as follows:

Before line 1, insert -- This application is the national phase under 35 U.S.C. § 371 of PCT International Application No. PCT/JP00/07239 which has an International filing date of October 18, 2000, which designated the United States of America and was not published in English.

Û 

MKM/tf

1163-0345P

## REMARKS

The specification has been amended to provide a cross-reference to the previously filed International Application.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

Ву\_

Michael K. Mutter, #29,680

P.O. Box 747

Fa/ls/Church, VA 22040-0747

(703/) 205-8000

(Rev. 02/12/01)

#### ACOUSTIC WAVE APPARATUS

This application is the national phase under 35 U.S.C. § 371 of PCT International Application No. PCT/JP00/07239 which has an International filing date of October 18, 2000, which designated the United States of America and was not published in English.

## BACKGROUND OF THE INVENTION

#### Technical Field

The present invention relates to an acoustic wave apparatus for propagating acoustic waves, used for the circuit of a communication equipment, an electronic device or the like.

#### Background Art

Heretofore, in such an acoustic wave apparatus in which a piezoelectric substrate containing tantalic acid lithium (LiTaO $_3$ , referred to as LT hereinafter) has been used, the cut angle  $\theta$  of the LT substrate has been set equal to 36°. This setting was a result of the calculation that if an electrode was formed on the surface of such a substrate, and the substrate surface was electrically short-circuited, the amount of propagation loss would be reduced to nearly a value of zero.

However, such calculation was made by assuming the establishment of an ideal state where the electrode had no thickness. Consequently, in the actual acoustic wave apparatus comprising an electrode having thickness, there was a possibility that a condition for reducing the amount of propagation loss to a minimum may be different. In addition, the calculation was made by examining the case where the entire surface of the substrate was covered with the electrode. Consequently, in the acoustic wave apparatus comprising electrode fingers cyclically arrayed as in the case of an SAW filter, there was a possibility

that a condition for reducing the amount of propagation loss to a minimum might be different.

Thus, in Japanese Patent Application Laid-Open No. 1997-167936 (referred to as a document 1, hereinafter), a condition for reducing the amount of propagation loss to a minimum is examined by taking into consideration the thickness of a grating electrode formed on the surface of the LT substrate. Fig. 1 shows the result of calculating the amount of propagation loss in a ladder surface acoustic wave filter of the document 1 shown in Fig. 7. In the drawing, an ordinate indicates the amount of loss made when a surface acoustic wave (referred to as SAW, hereinafter) is propagated per wavelength  $(\lambda)$ , i.e., the amount of loss per wavelength  $(dB/\lambda)$ . An abscissa indicates a standardized electrode thickness  $(h/\lambda)$ , where the thickness h of the electrode is standardized based on the wavelength  $\lambda$  of SAW.

Fig. 1 shows the case where an LT crystal X-axis direction is set as a SAW propagation direction, a surface perpendicular to a " $\theta$ -rotated Y" axis obtained by rotating a crystal Y axis by  $\theta$  around the crystal X axis, is set as a substrate surface, and a cut angle  $\theta$  is set in the range of 36° to 46°. The LT substrate having the surface perpendicular to the " $\theta$ -rotated Y" axis set as its surface and the crystal X-axis direction set as the SAW propagation direction is represented by  $\theta$ -rotated Y-cut X-propagation tantalic acid lithium, abbreviated to  $\theta$ YX-LT, or  $\theta$ YX-LiTaO3. In many cases, the electrode is made of aluminum (Al) or an alloy mainly containing Al.

As shown in Fig. 1, if a standardized electrode thickness  $(h/\lambda)$  is 0, the amount of loss per wavelength  $(dB/\lambda)$  is minimum when a cut angle  $\theta$  is about  $36^{\circ}$ . This result coincides with that of the conventional calculation, i.e., if the ideal state of the electrode having no thickness is established, the amount of propagation loss is reduced to nearly a value of zero when a cut angle  $\theta$  is  $36^{\circ}$ .

In addition, as shown in Fig. 1, if a cut angle  $\theta$  is  $40^{\circ}$ , the amount of loss per wavelength (dB/ $\lambda$ ) is minimum when a standardized electrode thickness (h/ $\lambda$ ) is about 0.05. If a cut angle  $\theta$  is 42°, the amount of loss per wavelength (dB/ $\lambda$ ) is minimum when a standardized electrode thickness (h/ $\lambda$ ) is about 0.075. Accordingly, in the SAW device realized by setting the standardized electrode thickness (h/ $\lambda$ ) in a range above 0.05, a cut angle  $\theta$  for reducing the amount of propagation loss to a minimum resides in a range above  $40^{\circ}$ .

As apparent from the foregoing discussion made with reference to Fig. 1, it is possible to reduce the amount of propagation loss to a minimum by selecting the proper combination of a standardized electrode thickness  $(h/\lambda)$  with a cut angle  $\theta$ . As a result, the insertion loss of the SAW device can be reduced. Therefore, in recent years, the LT substrate having a cut angle  $\theta$  set equal to 42° has been employed.

There are several kinds of acoustic waves. If a cut angle  $\theta$  is set in the range of about 36° to 46°, and the direction of propagation is a crystal X axis, for example, a surface skimming bulk wave (SSBW), which is a bulk wave propagated along the surface of an LT substrate described in a document: pp. 158-165, "Journal of Institute of Electronics and Communication Engineers of Japan", Vo 1. J67-C, No. 1, Jan. 1984 (referred to as a document 2, hereinafter), and a leaky surface acoustic wave (LSAW) are propagated. In the present application, these waves are generically termed as SAW, except when the waves are distinguished from each other.

Fig. 2 is an upper surface view showing the constitution of the SAW filter, which is one type of an acoustic wave apparatus. In the drawing, a reference numeral 1 denotes an LT substrate made of a piezoelectric material; 3 an electrode finger; 4 a bonding pad; 5 an input side interdigital transducer (IDT) for performing

electric - surface acoustic wave energy conversion; 6 an output side IDT for performing surface acoustic wave - electric energy conversion; 7 an input terminal; and an 8 an output terminal. WO represents a maximum value of the length of a portion intersected by the electrode finger 3.

Fig. 3 is a sectional view of the SAW filter shown in Fig. 2. In the drawing, a code w represents a width of the electrode finger 3; p an arraying cycle of electrode fingers 3; and h a thickness of the electrode finger 3.

Next, the operation of the SAW filter will be described.

An electric signal applied to the input terminal 7 forms an electric field at the intersection of each electrode finger 3 of the input side IDT 5. In this case, as the LT substrate 1 is made of the piezoelectric material, the electric field causes distortion. If the input signal has a frequency f, the strain that has been generated is vibrated at the frequency f, converting the signal into SAW. This SAW is then transmitted in a direction perpendicular to the electrode finger 3. At the output side IDT 6, the SAW is converted back into the electric signal. The conversion of the electric signal into the SAW, and the conversion of the SAW into the electric signal are reversible to each other.

If a cut angle  $\theta$  is about 36°, and the propagation direction of the SAW is in a crystal X-axis direction, as described in the document 2, the displacement component of the SAW has a direction parallel to the electrode finger 3, and the surface of the LT substrate 1. Such a displacement component depends on the cut angle  $\theta$  of the cut surface of the LT substrate 1 and the propagation direction of the SAW.

The SAW excited by the input side IDT 5 is propagated toward the output side IDT 6. However, if there is propagation loss in the LT substrate 1, the power of the SAW having reached the output side IDT 6 is smaller than that of the SAW immediately after its excitation by the

input side IDT 5. The amount of the loss is approximately equal to a value obtained by multiplying a distance between the centers of the input side IDT 5 and the output side IDT 6 standardized based on the wavelength  $\lambda$  of the SAW by an attenuation constant  $\alpha$ .

Thus, assuming that the distances of the input side IDT 5 and the output side IDT 6 are equal to each other, as the amount of propagation loss in the LT substrate 1 is increased, the amount of insertion loss for the SAW filter is larger. As described in a document: pp. 56 to 81, "Surface Acoustic Wave Engineering", Institute of Electronics and Communication Engineers of Japan, issued by Corona Inc., Nov. 1983, since the wavelength  $\lambda$  of the SAW is double the arraying cycle p of the electrode fingers 3, the amount of loss generated following propagation is approximately equal to a value, which is obtained by multiplying a numerical value half an average value of the numbers of electrode fingers 3 constituting the input side IDT 5 and the output side IDT 6 by an attenuation constant  $\alpha$ .

For example, as shown in Fig. 2, assuming that each of the input side IDT 5 and the output side IDT 6 has 7 electrode fingers 3, and the input side IDT 5 and the output side IDT 6 are disposed close to each other, the amount of loss generated following propagation is equal to a value, which is about 3 to 4 times larger than the attenuation constant  $\alpha$ . As an example, if an attenuation constant  $\alpha$  is 0.02 (dB/ $\lambda$ ), then the amount of loss following propagation takes a value set in the range of 0.06 to 0.08 dB.

As apparent from the foregoing, in order to realize a low-loss SAW device, it is important to use an LT substrate 1 having a small amount of propagation loss. Heretofore, in the acoustic wave apparatus of the foregoing type, a cut angle  $\theta$  set in a range above 36° has been employed.

As described above, the propagation loss greatly

affects the insertion loss of the SAW filter. However, the propagation loss is not the only factor that affects the insertion loss of the SAW filter. As material constants for representing the characteristics of the LT substrate 1, in addition to the propagation loss, there are an electromechanical coupling coefficient k² regarding conversion efficiency between the electric signal and the SAW, a capacitance CO regarding the impedance of the input or output side IDT 5 or 6, the propagation velocity Vs of the SAW, and so on. Among these constants, the electromechanical coupling coefficient k² is particularly important, because it decides the insertion loss or the pass band width of the SAW filter.

For the acoustic wave apparatus using a pure surface acoustic wave bringing about no propagation loss in principle, such as a Rayleigh wave, Bleustein-Gulyaev-Shimizu (BGS) wave or the like, optimal designing conditions were known. However, for the acoustic wave apparatus using LSAW or SSBW, no specific conditions were known.

As described above, the conventional acoustic wave apparatus of the foregoing type has been used under the condition for minimizing the propagation loss. However, since the electromechanical coupling coefficient  $k^2$  for greatly affecting the characteristics of the acoustic wave apparatus has not been used under any optimal conditions, deterioration has inevitably occurred in the insertion loss or the band width of the acoustic wave apparatus.

The present invention was made to solve the foregoing problems, and it is an object of the invention to provide an acoustic wave apparatus with lower loss characteristics and wider band than the conventional acoustic wave apparatus of the foregoing type.

## DISCLOSURE OF THE INVENTION

In accordance with the present invention, there is

provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of  $34^{\circ}$  to  $41^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as the surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of  $35^{\circ}$  to  $42^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as the surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.05 to 0.075, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided

an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of  $36^{\circ}$  to  $43^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$ obtained by standardizing a thickness h of an electrode finger constituting at least a part of the reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$ obtained by standardizing a thickness h of an electrode finger constituting at least a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.05 to 0.075, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 36° to 43° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$ obtained by standardizing a thickness h of an electrode finger constituting at least a part of the reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss

characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.05 to 0.75, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss

characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and an interdigital transducer including a conductor formed on the substrate. In this case, a surface rotated in the range of  $36^{\circ}$  to  $43^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of the interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$ obtained by standardizing a thickness h of a part of an electrode finger constituting a part of the reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.01 to 0.05, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arraying cycle p of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$ obtained by standardizing a thickness h of a part of an electrode finger constituting a part of the reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.05 to 0.075, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arranging cycle of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

In accordance with the invention, there is provided an acoustic wave apparatus, comprising: a piezoelectric substrate mainly containing tantalic acid lithium; an interdigital transducer including a conductor formed on the substrate; and a reflector including a conductor formed on the substrate. In this case, a surface rotated in the range of 36° to 43° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of the substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of a part of an electrode finger constituting a part of the reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in the range of 0.075 to 0.1, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arraying

cycle p of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

Thus, an acoustic wave apparatus with lower loss characteristics and wider band characteristics than the conventional apparatus can be realized.

## BRIEF DESCRIPTION OF THE DRAWINGS

- Fig. 1 is a view showing a result of calculating an attenuation constant, described in Japanese Patent Application Laid-Open No. 1997-167936.
- Fig. 2 is an upper surface view showing a constitution of an SAW filter.
- Fig. 3 is a sectional view of the SAW filter shown in Fig. 2.
- Fig. 4 is a view showing a result of calculating an attenuation constant when a standardized electrode thickness is set equal to 0.01, according to a first embodiment of the present invention.
- Fig. 5 is a view showing a result of calculating an electromechanical coupling coefficient when the standardized electrode thickness is equal to 0.01, according to the first embodiment of the invention.
- Fig. 6 is a view showing a result of calculating an attenuation constant when a standardized electrode thickness is set equal to 0.05, according to the first embodiment of the invention.
- Fig. 7 is a view showing a result of calculating an electromechanical coupling coefficient when the standardized electrode thickness is equal to 0.05, according to the first embodiment of the invention.
- Fig. 8 is a view showing a result of calculating an attenuation constant when a standardized electrode thickness is set equal to 0.075, according to the first embodiment of the invention.
- Fig. 9 is a view showing a result of calculating an electromechanical coupling coefficient when the

standardized electrode thickness is equal to 0.075, according to the first embodiment of the invention.

Fig. 10 is a view showing a result of calculating an attenuation constant in an LT substrate when a standardized electrode thickness is set equal to 0.1, according to the first embodiment of the invention.

Fig. 11 is a view showing a result of calculating an electromechanical coupling coefficient in the LT substrate when the standardized electrode thickness is equal to 0.1, according to the first embodiment of the invention.

Fig. 12 is a view showing a pattern of a mode-coupled SAW resonant filter.

Fig. 13 is a view showing a result of calculating a minimum insertion loss value of the mode-coupled SAW resonant filter shown in Fig. 12.

Fig. 14 is a view showing a result of calculating feedthrough power of the mode-coupled SAW resonant filter shown in Fig. 12.

## BEST MODE FOR CARRYING OUT THE INVENTION

Several embodiments for carrying out best the present invention are now explained in detail with reference to attached drawings.

#### [First Embodiment]

Fig. 4 is a view showing the result of calculating an attenuation constant  $\alpha$  when a standardized electrode thickness  $(h/\lambda)$  is 0.01. In the drawing, an ordinate indicates an attenuation constant  $\alpha$   $(dB/\lambda)$ ; and an abscissa a cut angle  $\theta$  of an LT substrate. As in the case shown in Fig. 1, the crystal X-axis direction of the LT substrate is set as the propagation direction of SAW, and a surface perpendicular to the axis of rotating a crystal Y axis by  $\theta$  around the crystal X axis, i.e., the surface of rotating the crystal Y axis by  $\theta$  around the crystal X axis, is set as the surface of the LT substrate.

In the described case, calculation is made as to the propagation characteristic of SAW when electrode fingers each having a width w like that shown in Fig. 3 are endlessly arrayed at an arraying cycle p. Fig. 4 specifically shows the results of calculation made by changing the duty ratio (w/p) of the electrode finger decided based on the width w and the arraying cycle p of the electrode finger from 0.2 to 0.8 each by 0.1.

Fig. 5 is a view showing the result of calculating an electromechanical coupling coefficient  $\mathbf{k}^2$  when a standardized electrode thickness  $(h/\lambda)$  is 0.01. In the drawing, an ordinate indicates an electromechanical coupling coefficient  $\mathbf{k}^2$ ; and an abscissa a cut angle  $\theta$  of the LT substrate as in the case shown in Fig. 4. Fig. 5 shows the results of calculation made by changing the duty ratio (w/p) based on the same values as those shown in Fig. 4.

The results of calculation shown in Figs. 4 and 5 are based on the methods of analysis using discrete Green function respectively described in, for example, a document: pp. 649 to 654, "Recent Studies on Acoustic Wave Device Technology-Committee Report-, March, 1995, by Acoustic Wave Device Technology 150th Committee of Japan Society for the Promotion of Science (referred to as a document 4, hereinafter), a document: pp. 786 to 791 of the same (document 5, hereinafter), and a document: pp. 93 to 100, 23rd EM Symposium, May, 1994 (document 6, hereinafter). The back scattering effect of a program (FEMSDA) described in the document 5 is excluded in the results of calculation.

Similarly to Figs. 4 and 5, Figs. 6 and 7 show the results of calculation each made when a standardized electrode thickness  $(h/\lambda)$  is 0.05. The value 0.05 of the standardized electrode thickness  $(h/\lambda)$  is used relatively frequently in the SAW device of a GHz band.

Referring to Fig. 6, a cut angle  $\theta$  with respect to a minimum attenuation constant  $\alpha$  is shown to be larger than

that shown in Fig. 4. In Fig. 7, however, if a cut angle  $\theta$  is selected for a smaller attenuation constant  $\alpha$ , an electromechanical coupling coefficient  $k^2$  is smaller. In other words, as shown in Fig. 6, an attenuation constant  $\alpha$  takes a minimum value when a cut angle  $\theta$  is about 38°. But an electromechanical coupling coefficient  $k^2$  takes a larger value when a cut angle  $\theta$  is lower than 38°.

Similarly to Figs. 4 and 5, or Figs. 6 and 7, Figs. 8 and 9 show the results of calculation each made when a standardized electrode thickness (h/ $\lambda$ ) is 0.075. Referring to Fig. 8, a cut angle  $\theta$  with respect to a minimum attenuation constant  $\alpha$  is shown to be larger than that shown in Fig. 6. An attenuation constant  $\alpha$  is minimum when a cut angle  $\theta$  is about 39°. In Fig. 9, however, if a cut angle  $\theta$  is selected for a smaller attenuation constant  $\alpha$ , an electromechanical coupling coefficient  $k^2$  is smaller. In other words, an electromechanical coupling coefficient  $k^2$  takes a larger value when a cut angle  $\theta$  is lower than 39°.

Similarly to Figs. 4 and 5, Figs. 6 and 7, or Figs. 8 and 9, Figs. 10 and 11 show the results of calculation each made when a standardized electrode thickness  $(h/\lambda)$  is 0.1. Referring to Fig. 10, a cut angle  $\theta$  with respect to a minimum attenuation constant  $\alpha$  is shown to be larger than that shown in Fig. 8. An attenuation constant  $\alpha$  is minimum when a cut angle  $\theta$  is about 40°. In Fig. 11, however, if a cut angle  $\theta$  is selected for a smaller attenuation constant  $\alpha$ , an electromechanical coupling constant  $k^2$  is smaller. In other words, an electromechanical coupling coefficient  $k^2$  takes a larger value when a cut angle  $\theta$  is lower than  $40^\circ$ .

In Fig. 6, for example, if a duty ratio (w/p) is 0.5, an attenuation constant  $\alpha$  takes a minimum value substantially equal to 0 when a cut angle  $\theta$  is about 38°. However, in the case of the calculation result for the conventional acoustic wave apparatus of such a type, shown

in Fig. 1, if a standardized electrode thickness  $(h/\lambda)$  is 0.05, an attenuation constant  $\alpha$  takes a minimum value equal to 0 when a cut angle  $\theta$  is about 40°. This is attributed to the fact that the calculation result of Fig. 1 is for the ladder surface acoustic wave filter according to the document 1, and is different from the calculation result for the acoustic wave apparatus constructed by arraying the electrode fingers at an endless cycle.

Fig. 12 shows the pattern of a mode-coupled SAW resonant filter, used to determine the effects of the calculation results shown in Figs. 4 to 11 on the SAW filter. In the drawing, a reference numeral 5 denotes an input side IDT. There are 31 electrode fingers 3 provided. A reference numeral 6 denotes an output side IDT. Two output sides IDT 6 are electrically connected in parallel with each other. One side of the output side IDT 6 has 18 electrode fingers 3, while the other side has 20 electrode fingers 3. A reference numeral 9 denotes a grating reflector, which has 120 electrode fingers (i.e., strips) 10 in one side. The line widths of the electrode fingers 3 of the input and output side IDT 5 and 6 are all equal to one another at wi, and also arraying cycles all equal to one another at pi.

The arraying cycle pg of the electrode fingers 10 of the grating reflector 9 shown in Fig. 12 is set at pg=1.0251 pi, different from those of the input and output side IDT 5 and 6. The duty ratio (wg/pg) of the electrode fingers 10 of the grating reflector 9 is equal to that (wi/pi) of the electrode fingers 3 of each of the input and output side IDT 5 and 6. Hereinafter, these duty ratios (wi/pi) and (wg/pg) are generically referred to as a duty ratio (w/p).

Distances D1 and D2 are respectively 2.5 pi and 0.25 pi. A maximum intersection width is 360  $\mu m\,.$ 

Fig. 13 shows the result of calculating a minimum insertion loss value for the SAW filter shown in Fig. 12.

Specifically, Fig. 13 shows the results of calculation made by changing duty ratios (w/p) from 0.5 to 0.7 each by 0.1, when a standardized electrode thickness  $(h/\lambda)$  is 0.05 for each of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9.

For the calculation, for example, a document: pp. 185 to 205, "Acoustic Wave Device Technology Handbook", Nov. 1991, by Acoustic Wave Device Technology 150th Committee of Japan Society for the Promotion of Science (referred to as a document 7, hereinafter) is available. In the described case, specifically, a 2nd equivalent circuit model by Smith described therein (Fig. 3.76, p. 188 of the document 7) is used for the input and output side IDT 5 and 6.

For the grating reflector 9, for example, a document: pp. 206 to 227, "Acoustic Wave Device Technology Handbook", Nov. 1991, by Acoustic Wave Device Technology 150th Committee of Japan Society for the Promotion of Science (referred to as a document 8, hereinafter) is available. In the described case, specifically, a distributed constant equivalent circuit described therein (right side of Fig. 3.134, p. 221 of the document 8) is used.

The change of a cut angle  $\theta$  or a duty ratio (w/p) causes a change in the propagation velocity Vs of SAW. In the described case, however, calculation is made by changing an arraying cycle pi in such a way as to set a center frequency f0 of each of the input and output side IDT 5 and 6 equal to 965MHz. In addition, the calculation is made by taking into consideration not only the changes of an attenuation constant  $\alpha$  and an electromechanical coupling coefficient  $k^2$ , but also the changes of material constants for the SAW propagation velocity Vs, a capacitance CO, a reflection coefficient C1, and so on.

Referring to Fig. 13, a value of insertion loss is shown to be minimum when a cut angle  $\theta$  is about 38°, which is smaller than that used in the conventional acoustic wave

apparatus of such a type when a cut angle  $\theta$  is 36° or 42°. Referring to Fig. 6, an attenuation constant  $\alpha$  is shown to be minimum when a cut angle  $\theta$  is 38°. This explains why the value of insertion loss is minimum when the cut angle  $\theta$  is about 38°. It can therefore be understood that the attenuation constant  $\alpha$  greatly affects the amount of insertion loss.

Fig. 14 shows the result of calculating feedthrough power for the SAW filter shown in Fig. 12. Specifically, Fig. 14 shows the results of calculation made by changing cut angles  $\theta$  to 36°, 38° and 42°, when a standardized electrode thickness (h/ $\lambda$ ) of each of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is 0.05, and a duty ratio (w/p) is 0.7.

In addition, the calculation is made by assuming that when a cut angle  $\theta$  is  $36^{\circ}$ , an acoustic velocity Vs is 4083.4~(m/s), an attenuation constant  $\alpha$  0.01749 (dB/ $\lambda$ ), a capacitance C0 304 (pF/m) per electrode finger, and an electromechanical coupling coefficient  $k^2$  11.7 %; when a cut angle  $\theta$  is  $38^{\circ}$ , an acoustic velocity Vs is 4085.6~(m/s), an attenuation constant  $\alpha$  8×10<sup>-6</sup> (dB/ $\lambda$ ), a capacitance C0 304 (pF/m) per electrode finger, and an electromechanical coupling coefficient  $k^2$  11.4 %; and when a cut angle  $\theta$  is  $42^{\circ}$ , an acoustic velocity Vs is 4088.3~(m/s), an attenuation constant  $\alpha$  0.00833 (dB/ $\lambda$ ), a capacitance C0 302 (pF/m) per electrode finger, and an electromechanical coupling coefficient  $k^2$  11.0 %.

As shown in Fig. 14, feedthrough power is only slightly lower when the cut angle  $\theta$  is 36° compared with that when the cut angle  $\theta$  is 38°. However, when the cut angle  $\theta$  is 42°, feedthrough power is lower by 0.1 dB or more compared with that when the cut angle  $\theta$  is 38°. As shown in Fig. 6, an attenuation constant  $\alpha$  is larger when the cut angle  $\theta$  is 36° or 42°, compared with that when the cut angle  $\theta$  is 38°. As shown in Fig. 7, an

electromechanical coupling coefficient k2 is larger when the cut angle  $\theta$  is 36°, compared with that when the cut angle  $\theta$  is 38°. When the cut angle  $\theta$  is 42°, an electromechanical coupling coefficient k2 is smaller compared with that when the cut angle  $\theta$  is 38°. The only slightly lower level of the feedthrough power when the cut angle  $\theta$  is 36° compared with that when the cut angle  $\theta$  is 38° can be attributed to the fact that when the cut angle  $\theta$ is 36°, not only the attenuation constant  $\alpha$  but also the electromechanical coupling coefficient k<sup>2</sup> are larger than those when the cut angle  $\theta$  is 38°. The lower level of the feedthrough power by 0.1 dB or more when the cut angle  $\theta$  is  $42^{\circ}$  compared with that when the cut angle  $\theta$  is  $38^{\circ}$  can be attributed to the fact that when the cut angle  $\theta$  is 42°, the attenuation constant  $\alpha$  is larger than that when the cut angle  $\theta$  is 38°, but the electromechanical coupling coefficient  $k^2$  is smaller. Accordingly, it can be understood that the electromechanical coupling coefficient k<sup>2</sup> also affects the amount of insertion loss greatly.

As can be understood from Fig. 7, the increase of the duty ratio (w/p) brings about a larger electromechanical coupling coefficient  $k^2$ , reducing the amount of insertion loss and widening a pass band width. Even if the larger attenuation constant  $\alpha$  increases the amount of loss following propagation, a corresponding increase if made in the electromechanical coupling coefficient  $k^2$  results in a reduction in the amount of insertion loss.

As shown in Fig. 4, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 37° and, by setting the cut angle  $\theta$  in the range of 34° to 40°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ). In addition, as shown Fig. 6, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 38° and, by setting the cut angle  $\theta$  in the range of 35° to 41°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ).

As shown in Figs. 5 and 7, when the cut angle  $\theta$  is

set in the range of 34° to 41°, the cut angle  $\theta$  is 36° or 42° if the duty ratio (w/p) is 0.6 or higher. The electromechanical coupling coefficient  $k^2$  is larger than that in the conventional case having the duty ratio (w/p) of 0.5. In the case having a large standardized electrode thickness (h/ $\lambda$ ) shown in Fig. 7, compared with that shown in Fig. 5, the electromechanical coupling coefficient  $k^2$  is larger under equal cut angles  $\theta$  and equal duty ratios (w/p). There have been no reports made hitherto regarding the result of calculating an electromechanical coupling coefficient based on consideration given to the duty ratio. Thus, in the described case, a general duty ratio 0.5 was used as a conventional duty ratio. The same applies hereinafter.

As described above, according to the first embodiment, the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of each of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ration (w/p) of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set to the value ranging from 0.6 to just below 1.0. Thus, it is possible to realize an acoustic wave apparatus with lower loss characteristics and wider band characteristics as compared with the conventional acoustic wave apparatus of such a type.

Such an advantage can be obtained not only when the input and output side IDT 5 and 6 and the grating reflector 9 all satisfy the above-described conditions, but also when only one of the components satisfies the conditions.

For example, a similar advantage can be obtained when only the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of the

electrode finger 3 of the input side IDT 5 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the input side IDT 5 is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode3 thickness of the electrode finger 3 of the output side IDT 6 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the output side IDT 6 is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when only the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of the electrode finger 10 of the grating reflector 9 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 10 of the grating reflector 9 is set to the value ranging from 0.6 to just below 1.0.

In addition, the foregoing advantage can be obtained not only when all the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9 satisfy the conditions, but also when a part of the electrode fingers satisfies the conditions.

For example, a similar advantage can be obtained when a part of the electrode fingers 3 of the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set

to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when a part of the electrode fingers 3 of the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, and the electrode thickness of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of a part of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

Furthermore, the foregoing advantage can obtained not only when all portions of a part of the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9 satisfy the conditions, but also when only a portion thereof satisfies the conditions.

For example, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of a portion of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the

output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of  $34^{\circ}$  to  $41^{\circ}$ , the electrode thickness of a portion of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when only a portion of a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 34° to 41°, the electrode thickness of a portion of a part of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.01 to 0.05 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

## [Second Embodiment]

As shown in Fig. 6, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 38° and, by setting the cut angle  $\theta$  in the range of 35° to 41°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ). In addition, as shown in Fig. 8, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 39° and, by setting the cut angle  $\theta$  in the range of 36° to 42°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ).

As shown in Figs. 7 and 9, when the cut angle  $\theta$  is set in the range of 35° to 42°, and the duty ratio (w/p) is 0.6 or higher, the electromechanical coupling coefficient  $k^2$  is larger than that in the conventional case in which the cut angle  $\theta$  is 36° and the duty ratio (w/p) is 0.5. In the case having a large standardized electrode thickness (h/ $\lambda$ ) shown in Fig. 9, compared with that shown in Fig. 7, the electromechanical coupling coefficient  $k^2$  is larger

under equal cut angles  $\theta$  and equal duty ratios (w/p).

As described above, according to the second embodiment, the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of each of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set to the value ranging from 0.6 to just below 1.0. Thus, it is possible to realize an acoustic wave apparatus with lower loss characteristics and wider band characteristics as compared with the conventional acoustic wave apparatus of such a type.

Such an advantage can be obtained not only when the input and output side IDT 5 and 6 and the grating reflector 9 all satisfy the foregoing conditions, but also when only one of the components satisfies the conditions.

For example, a similar advantage can be obtained when only the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of the electrode finger 3 of the input side IDT 5 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the input side IDT 5 is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of the electrode finger 3 of the output side IDT 6 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the output side IDT 6 is set to the value ranging from 0.6 to

just below 1.0.

Likewise, a similar advantage can be obtained when only the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of the electrode finger 10 of the grating reflector 9 is set in the range of 0.05 to 0.07 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 10 of the grating reflector 9 is set to the value ranging from 0.6 to just below 1.0.

In addition, the foregoing advantage can be obtained not only when all the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9 satisfy the conditions, but also when a part of the electrode fingers satisfies the conditions.

For example, a similar advantage can be obtained when a part of the electrode fingers 3 of the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when a part of the electrode fingers 3 of the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the

LT substrate is set in the range of  $35^{\circ}$  to  $42^{\circ}$ , the electrode thickness of a part of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

Furthermore, the foregoing advantage can be obtained not only when all portions of a part of the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9 satisfy the conditions, but also when only a portion thereof satisfies the conditions.

For example, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of a portion of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of a portion of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when only a portion of a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 35° to 42°, the electrode thickness of a portion of a part

of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.05 to 0.075 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

# [Third Embodiment]

As shown in Fig. 8, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 39° and, by setting the cut angle  $\theta$  in the range of 36° to 42°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ). In addition, as shown in Fig. 10, the attenuation constant  $\alpha$  takes a minimum value when the cut angle  $\theta$  is about 40° and, by setting the cut angle  $\theta$  in the range of 37° to 43°, the attenuation constant  $\alpha$  can be limited to 0.005 (dB/ $\lambda$ ).

As shown in Figs. 9 and 11, when the cut angle  $\theta$  is set in the range of 36° to 43°, and the duty ratio (w/p) is 0.6 or higher, the electromechanical coupling coefficient  $k^2$  is larger than that in the conventional case in which the cut angle  $\theta$  is 36° and the duty ratio (w/p) is 0.5. In the case having a large standardized electrode thickness (h/ $\lambda$ ) shown in Fig. 11, compared with that shown in Fig. 9, the electromechanical coupling coefficient  $k^2$  is larger under equal cut angles  $\theta$  and equal duty ratios (w/p).

As described above, according to the third embodiment, the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of each of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode fingers 3 and 10 respectively of the input and output side IDT 5 and 6 and the grating reflector 9 is set to the value ranging from 0.6 upto just below 1.0. Thus, it is possible to realize an acoustic wave apparatus with lower loss characteristics and wider band characteristics as compared

with the conventional acoustic wave apparatus of such a type.

Such an advantage can be obtained not only when the input and output side IDT 5 and 6 and the grating reflector 9 all satisfy the foregoing conditions, but also when only one of the components satisfies the conditions.

For example, a similar advantage can be obtained when only the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of the electrode finger 3 of the input side IDT 5 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the input side IDT 5 is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of the electrode finger 3 of the output side IDT 6 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 3 of the output side IDT 6 is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when only the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of the electrode finger 10 of the grating reflector 9 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of the electrode finger 10 of the grating reflector 9 is set to the value ranging from 0.6 to just below 1.0.

In addition, the foregoing advantage can be obtained not only when all the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9 satisfy

the conditions, but also when a part of the electrode fingers satisfies the conditions.

For example, a similar advantage can be obtained when a part of the electrode fingers 3 of the input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when a part of the electrode fingers 3 of the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of 36° to 43°, the electrode thickness of a part of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

In addition, the foregoing advantage can be obtained not only when all portions of a part of the electrode fingers of the input and output side IDT 5 and 6 and the grating reflector 9, but also when only a portion thereof satisfies the conditions.

For example, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the

input side IDT 5 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of  $36^{\circ}$  to  $43^{\circ}$ , the electrode thickness of a portion of a part of the electrode fingers 3 of the input side IDT 5 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Similarly, a similar advantage can be obtained when only a portion of a part of the electrode fingers 3 of the output side IDT 6 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of  $36^{\circ}$  to  $43^{\circ}$ , the electrode thickness of a portion of a part of the electrode fingers 3 of the output side IDT 6 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 3 thereof is set to the value ranging from 0.6 to just below 1.0.

Likewise, a similar advantage can be obtained when only a portion of a part of the electrode fingers 10 of the grating reflector 9 satisfies the conditions, i.e., when the cut angle  $\theta$  of the LT substrate is set in the range of  $36^{\circ}$  to  $43^{\circ}$ , the electrode thickness of a portion of a part of the electrode fingers 10 of the grating reflector 9 is set in the range of 0.075 to 0.1 with respect to a wavelength of SAW, and the duty ratio (w/p) of a portion of a part of the electrode fingers 10 thereof is set to the value ranging from 0.6 to just below 1.0.

The invention has been described by taking the example of the mode-coupled SAW resonant filter shown in Fig. 12. However, the invention is not limited to such, and a similar advantage can be obtained even when a given number of IDT units other than 3 is prepared. Further, the invention is similarly advantageous even when it is applied to a so-called transversal filter having a multielectrode structure or the simply structured SAW filter shown in Fig.

2.

In addition, in the foregoing cases, the arraying cycles of the electrode fingers 3 were all similar. However, the invention is similarly advantageous even when the arraying cycles are partially or entirely changed. A similar advantage can also be obtained even in the case where there is a floating electrode in the IDT or floating electrodes present at different positions in the IDT are electrically connected to each other.

Furthermore, the present invention is advantageous not only for the SAW filter but also for all the other types of SAW devices including IDT having a function of conversion for the electric signal of a one terminal pair SAW resonator, a SAW delay line, a SAW dispersed delay line, a SAW convolver or the like with LSAW and SSBW. The invention is also advantageous for all acoustic wave apparatus using such SAW devices.

# Industrial Applicability

As apparent from the foregoing, the acoustic wave apparatus of the invention is suitable for realizing a characteristic of smaller loss and a wider band than those in the conventional art.

#### WHAT IS CLAIMED IS:

An acoustic wave apparatus comprising:
 a piezoelectric substrate mainly containing tantalic
 acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

An acoustic wave apparatus comprising:
 a piezoelectric substrate mainly containing tantalic
 acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.05 to 0.075, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode is set to the value ranging from 0.6 to just below 1.0.

3. An acoustic wave apparatus comprising:

a piezoelectric substrate mainly containing tantalic acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of 36° to 43° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

4. An acoustic wave apparatus comprising:

a piezoelectric substrate mainly containing tantalic acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting at least a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

5. An acoustic wave apparatus comprising:

a piezoelectric substrate mainly containing tantalic acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting at least a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.05 to 0.075, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

6. An acoustic wave apparatus comprising:
a piezoelectric substrate mainly containing

a piezoelectric substrate mainly containing tantalic acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of  $36^{\circ}$  to  $43^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting at least a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

7. An acoustic wave apparatus comprising:

a piezoelectric substrate mainly containing tantalic
acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of  $34^{\circ}$  to  $41^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

8. An acoustic wave apparatus comprising: a piezoelectric substrate mainly containing tantalic acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.05 to 0.75, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

9. An acoustic wave apparatus comprising: a piezoelectric substrate mainly containing tantalic

acid lithium; and

an interdigital transducer including a conductor formed on said substrate,

wherein a surface rotated in a range of  $36^{\circ}$  to  $43^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of an electrode finger constituting a part of said interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.075 to 0.1, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

10. An acoustic wave apparatus comprising:
a piezoelectric substrate mainly containing tantalic acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of 34° to 41° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of a part of an electrode finger constituting a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.01 to 0.05, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arraying cycle p of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

11. An acoustic wave apparatus comprising: a piezoelectric substrate mainly containing tantalic

acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of 35° to 42° from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of a part of an electrode finger constituting a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.05 to 0.075, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arranging cycle of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

12. An acoustic wave apparatus comprising:

a piezoelectric substrate mainly containing tantalic acid lithium;

an interdigital transducer including a conductor formed on said substrate; and

a reflector including a conductor formed on said substrate,

wherein a surface rotated in a range of  $36^{\circ}$  to  $43^{\circ}$  from a crystal Y axis around a crystal X axis of the tantalic acid lithium is set as a surface of said substrate, a standardized electrode thickness  $(h/\lambda)$  obtained by standardizing a thickness h of a part of an electrode finger constituting a part of said reflector by a wavelength  $\lambda$  of a surface acoustic wave is set in a range of 0.075 to 0.1, and a duty ratio (w/p) of a part of the electrode finger decided based on a width w and an arraying cycle p of a part of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

#### ABSTRACT OF THE DISCLOSURE

There is disclosed an acoustic wave apparatus, constructed in such a manner that a surface rotated in the range of 34° to 41° from a crystal Y axis around the crystal X axis of tantalic acid lithium is set as the surface of a substrate, a standardized electrode thickness ( $h/\lambda$ ) obtained by standardizing a thickness h of an electrode finger constituting at least a part of an interdigital transducer by a wavelength  $\lambda$  of a surface acoustic wave is set to the range of 0.01 to 0.05, and a duty ratio (w/p) of the electrode finger decided based on a width w and an arraying cycle p of the electrode finger is set to the value ranging from 0.6 to just below 1.0.

FIG.1

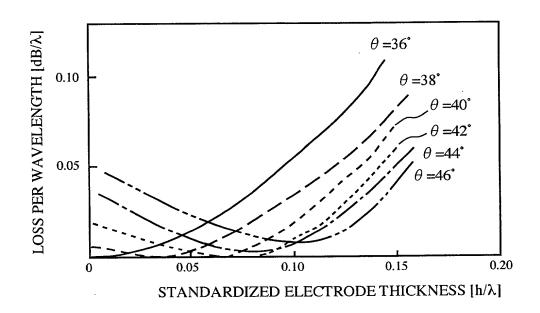
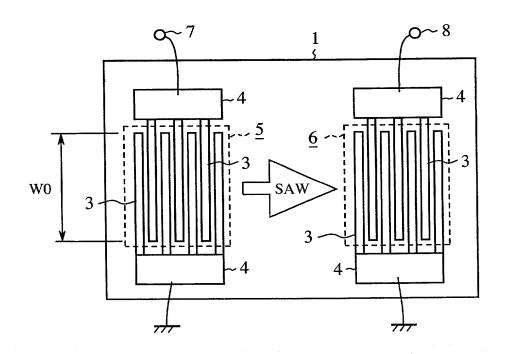


FIG.2



# FIG.3

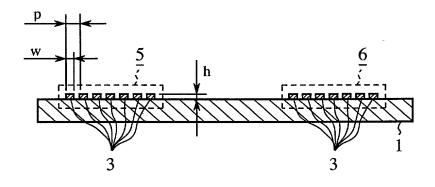


FIG.4

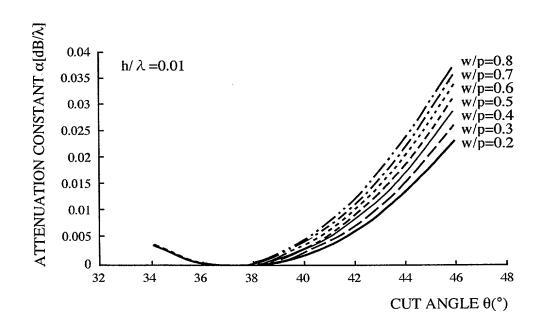


FIG.5

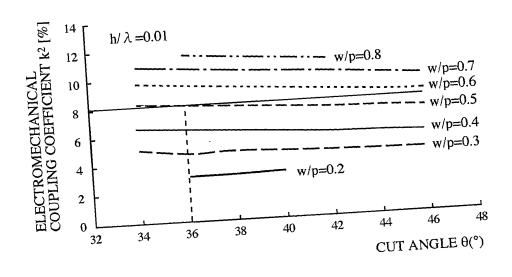


FIG.6

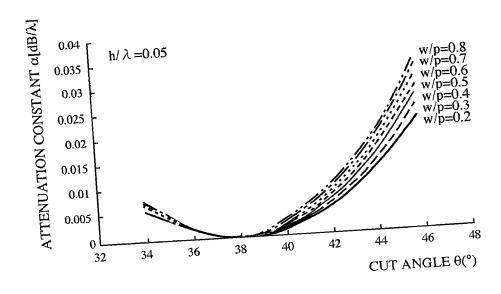


FIG.7

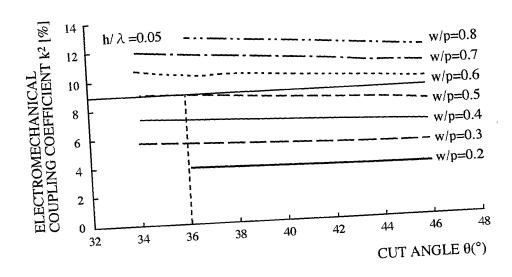
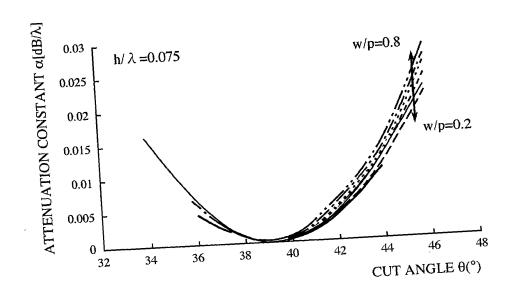


FIG.8



THE REAL PROPERTY AND THE PROPERTY AND T

FIG.9

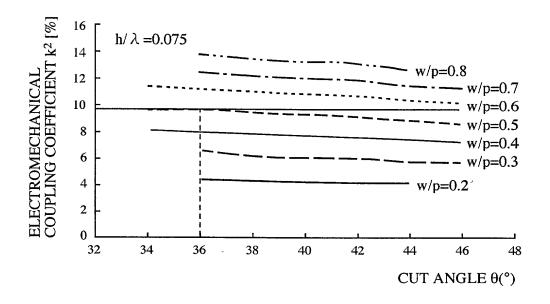
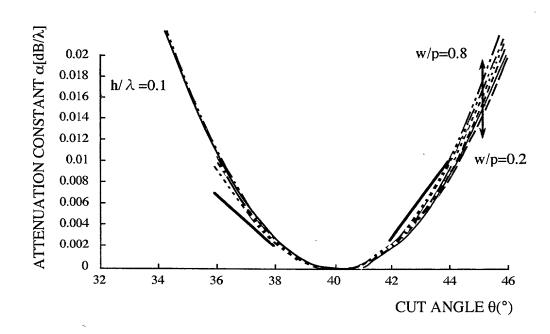


FIG.10



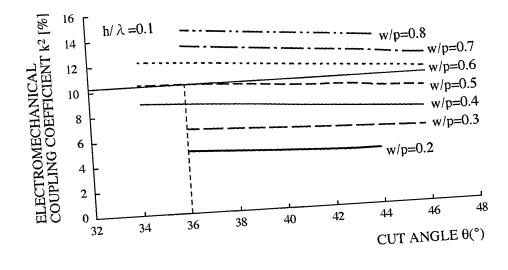
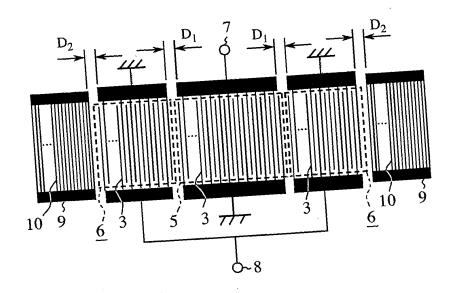


FIG.12



The first control of the first

# FIG.13

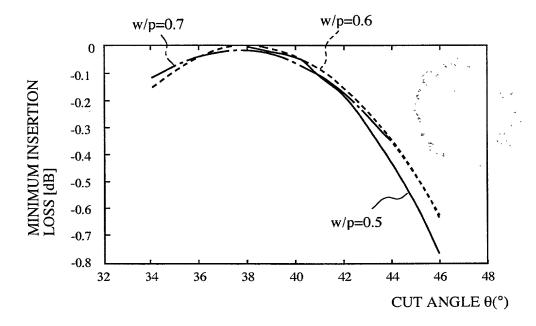
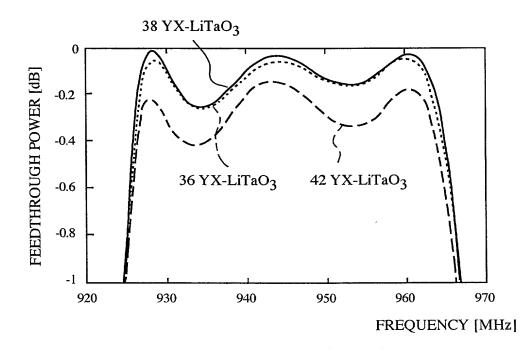


FIG.14



PTO/SB/106 (8-96)
Approved for use through 9/30/98. OMB 0651-0032
Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number.

### **Declaration and Power of Attorney For Patent Application**

特許出願宣言書及び委任状

#### **Japanese Language Declaration**

#### 日本語宣言書

下記の氏名の発明者として、私は以下の通り宣言します	. As a below named inventor, I hereby declare that:
私の住所、私書箱、国籍は下記の私の氏名の後に記載さ た通りです。	ਮੈ My residence, post office address and citizenship are as stated next to my name.
下記の名称の発明に関して請求範囲に記載され、特許出している発明内容について、私が最初かつ唯一の発明者(記の氏名が一つの場合)もしくは最初かつ共同発明者であと(下記の名称が複数の場合)信じています。	下 is listed below) or an original, first and joint inventor (if plural and names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled
	"ACOUSTIC WAVE APPARATUS"
上記発明の明細書(下記の欄でx印がついていない場合) 本書に添付)は、	the specification of which is attached hereto unless the following box is checked:
□月日に提出され、米国出顧番号または特許協定会 国際出顧番号をとし、 (該当する場合) に訂正されました。	was filed on <u>October 18, 2000</u> as United States Application Number or PCT International Application Number PCT/JP00/07239 and was amended on (if applicable).
私は、特許請求範囲を含む上記訂正後の明細書を検討し 内容を理解していることをここに表明します。	I hereby state that I have reviewed and understand the contents of the above identified specification, including the claims, as amended by any amendment referred to above.
私は、連邦規則法典第37編第1条56項に定義されるおり、特許資格の有無について重要な情報を開示する義務あることを認めます。	

PTO/S8/106 (8-96)
Approved for use through 9/30/98. OMB 0651-0032
Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number.

#### Japanese Language Declaration (日本語宜言書)

私は、米国法典第35編119条 (a)-(d)項又は365条 (b)項に基き下記の、米国以外の国の少なくとも一ヵ国を指定している特許協力条約365(a)項に基ずく国際出願、又は外国での特許出願もしくは発明者証の出願についての外国優先権をここに主張するとともに、優先権を主張している、本出顧の前に出願された特許または発明者証の外国出願を以下に、枠内をマークすることで、示しています。

Prior Foreign Application(s)

j

 外国での先行出順 11-325799
 Japan

 (Number) (番号)
 (Country) (国名)

 (Number) (番号)
 (Country) (国名)

私は、第35編米国法典119条(e)項に基いて下記の米国特許出題規定に記載された権利をここに主張いたします。

(Application No.) (Filing Date) (出願番号) (出顧日)

私は、下記の米国法典第35編120条に基いて下記の米国特許出頭に記載された権利、又は米国を指定している特許協力条約365条(c)に基ずく権利をここに主張します。また、本出題の各請求範囲の内容が米国法典第35編112条第1項又は特許協力条約で規定された方法で先行する米国特許出頭に開示されていない限り、その先行米国出願書提出日以降で本出願書の日本国内または特許協力条約国際提出日までの期間中に入手された、連邦規則法典第37編1条56項で定義された特許資格の有無に関する重要な情報について開示義務があることを認識しています。

(Application No.) (Filing Date)
(出頭番号) (出頭日)

(Application No.) (Filing Date)
(出頭番号) (出頭日)

私は、私自身の知識に基ずいて本宜言書中で私が行なう表明が真実であり、かつ私の入手した情報と私の信じるところに基ずく表明が全て真実であると信じていること、さらに故意になされた虚偽の表明及びそれと同等の行為は米国法典第18編第1001条に基ずき、罰金または拘禁、もしくはその両方により処罰されること、そしてそのような故意による虚偽の声明を行なえば、出頭した、又は既に許可された特許の有効性が失われることを認識し、よってここに上記のごとく宣誓を致します。

I hereby claim foreign priority under Title 35, United States Code, Section 119 (a)-(d) or 365(b) of any foreign application(s) for patent or inventor's certificate, or 365(a) of any PCT international application which designated at least one country other than the United States, listed below and have also identified below, by checking the box, any foreign application for patent or inventor's certificate, or PCT international application having a filing date before that of the application on which priority is claimed.

I hereby claim the benefit under Title 35. United States Code, Section 119(e) of any United States provisional application(s) listed below.

(Application No.) (Filing Date) (出類母)

I hereby claim the benefit under Title 35, United States Code, Section 120 of any United States application(s), or 365(c) of any PCT international application designating the United States, listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States or PCT International application in the manner provided by the first paragraph of Title 35, United States Code Section 112, I acknowledge the duty to disclose information which is material to patentability as defined in Title 37, Code of Federal Regulations, Section 1.58 which became available between the filing date of application and the national or PCT international filing date of application.

(Status: Patented, Pending, Abandoned) (現況:特許許可済、係属中、放棄済)

(Status: Patented, Pending, Abandoned) (現況: 特許許可済、係属中、放棄済)

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number.

### Japanese Language Declaration

(日本語宣言書)

委任状: 私は下記の発明者として、本出額に関する一切の 手続きを米特許商標局に対して遂行する弁理士または代理人 として、下記の者を指名いたします。(弁護士、または代理 人の氏名及び登録番号を明記のこと)

TERRELL C. BIRCH (Reg. No. 19,382)
RAYMOND C. STEWART (Reg. No. 21,066)
JOSEPH A. KOLASCH (Reg. No. 22,463)
ANTHONY L. BIRCH (Reg. No. 26,122)

JAMES M. SLATTERY (Reg. No. 28,380) BERNARD L. SWEENEY (Reg. No. 24,448) MICHAEL K. MUTTER (Reg. No. 29,680) CHARLES GORENSTEIN (Reg. No. 29,271) POWER OF ATTORNEY: As a named inventor, I hereby appoint the following attorney(s) and/or agent(s) to prosecute this application and transact all business in the Patent and Trademark Office connected therewith (list name and registration number)

GERALO M. MURPHY (Reg. No. 28,977) LEONARO R. SVENSSON (Reg. No. 30,330) TERRY L. CLARK (Reg. No. 32,844) ANDREW D. MEIKLE (Reg. No. 32,868)

MARC S. WEINER (Reg. No. 32,181) ANDREW F. REISH (Reg. No. 33,443) JOE M. MUNCY (Reg. No. 32,334) C. JOSEPH FARACI (Reg. No. 32,350)

查额送付先

ij

Send Correspondence to:

BIRCH, STEWART, KOLASCH & BIRCH, LLP P.O. 80X 747 FALLS CHURCH, VA 22040-0747 TEL: (703) 205-8000

直接電話連絡先: (/

(名前及び電話番号)

Direct Telephone Calls to: (name and telephone number)

BIRCH, STEWART, KOLASCH & BIRCH, LLP TEL: (703) 205-8000

唯一または第一発明者名 √Full name of sole or first inventor Kenji YOSHIDA 発明者の署名 日付 inventor's signature Date Kenri Torhida July 9. 2001 住所 Residence Tokyo, Japan 国籍 Citizenship Japanese 私書符. Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA 2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan 第二共同発明者 Full name of second joint inventor, if any Shusou WADAKA 第二共同発明者 日付 Second inventor's signature WADASO July 9, 2001 住所 Residence Tokyo, Japan 国籍 Citizenship Japanese 私杏箱 Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA 2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan

(第三以降の共同発明者についても同様に記載し、署名をすること)

(Supply similar information and signature for third and subsequent joint inventors.)

第3の共同発明者の氏名(該当する場合)	Full name of third joint inventor, if any, Koichiro MISU	
司第3発明者の署名	日付	Third Inventor's signature Date  Koichivo Miss July 9, 2001
主所		Residence Tokyo, Japan
<b>国籍</b>		Citizenship Japanese
郵便の宛先		Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA
		2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan
第4の共同発明者の氏名(該当する場合)		Full name of fourth joint inventor, if any, Tsutomu NAGATSUKA
同第4発明者の署名	日付	Fourth Inventor's signature Date Trutome Najagrifey July 9, 2001
住所		Residence Tokyo, Japan
国籍		Citizenship Japanese
郵便の宛先		Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA
		2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan
第5の共同発明者の氏名(該当する場合)		Full name of fifth joint inventor, if any, Kouji MURAI
同第5発明者の署名	日付	Fifth Inventor's signature Date  Kowj: Mura; July 9, 2001
住所		Residence Tokyo, Japan
国籍		Citizenship Japanese
郵便の宛先		Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA
		2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan

第6の共同発明者の氏名 (該当する場合)		
		Full name of sixth joint inventor, if any,  () Masatsune YAMAGUCHI
司第6発明者の署名 日第6発明者の署名	引付	Sixth Inventor's signature Date
		Masatsane Jamagerch July 9, 2001
主所		Residence Chiba, Japan
<b>国籍</b>		- Citizenship Japanese
郵便の宛先	<del>.</del>	Post Office Address 3-10-4, Miyanodai, Sakura-shi, Chiba
		285–0857 Japan
第7の共同発明者の氏名(該当する場合)		Full name of seventh joint inventor, if any,  Kenya HASHIMOTO
同第7発明者の署名	日付	Seventh Inventor's signature Date
		July 9, 2001
住所		Residence Chiba, Japan
国籍		Citizenship Japanese
郵便の宛先	,	Post Office Address 4-31-1, Futawanishi, Funabashi-shi,
		Chiba 274—0806 Japan
第8の共同発明者の氏名(該当する場合)		Full name of eighth joint inventor, if any,  Tatsuya OHMORI
同第8発明者の署名	日付	Eighth Inventor's signature Date  Tatsura Omori July 9, 2001
住所		Residence Chiba, Japan
国籍		Citizenship Japanese
郵便の宛先		Post Office Address
		6-7-18, Tsubakimori, Chuo-ku, Chiba-shi,
		Chiba 260-0042 Japan

第9の共同発明者の氏名 (該当する場合)			Full name of ninth joint inventor, if any, Koji IBATA		
	同第9発明者の署名	日付	Ninth Inventor's signature Kožī Iboto.	Date July 9, 2001	
	住所		Residence Tokyo, Japan		
	国籍		Citizenship Japanese		
	郵便の宛先	-	Post Office Address c/o MITSUBISHI DENKI KABUSHIKI KAISHA,		
			2-3, Marunouchi 2-chome, Chiyoda-ku, Tokyo 100-8310 Japan		
	第10の共同発明者の氏法	名(該当する場合)	Full name of tenth joint inventor, if any,		
Total Mark Total	同第10発明者の署名	日付	Tenth Inventor's signature	Date	
The state of the state of	住所		Residence	,	
76 to 110 11 11 11 11 11 11 11 11 11 11 11 11	国籍		Citizenship		
	郵便の宛先		Post Office Address		
第11の共同発明者の氏名 (該当する場合)		名(該当する場合)	Full name of eleventh joint inventor, if any,		
	同第11発明者の署名	日付	Eleventh Inventor's signature	Date	
	住所		Residence		
	国籍		Citizenship		
	郵便の宛先		Post Office Address		